

MSE 104, Fall 2017

Quiz No. 2, November 29, 2017

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Question	Points
1 (20 pts)	20
2 (25 pts)	25
3 (25 pts)	25
4 (30 pts)	30
Total	100

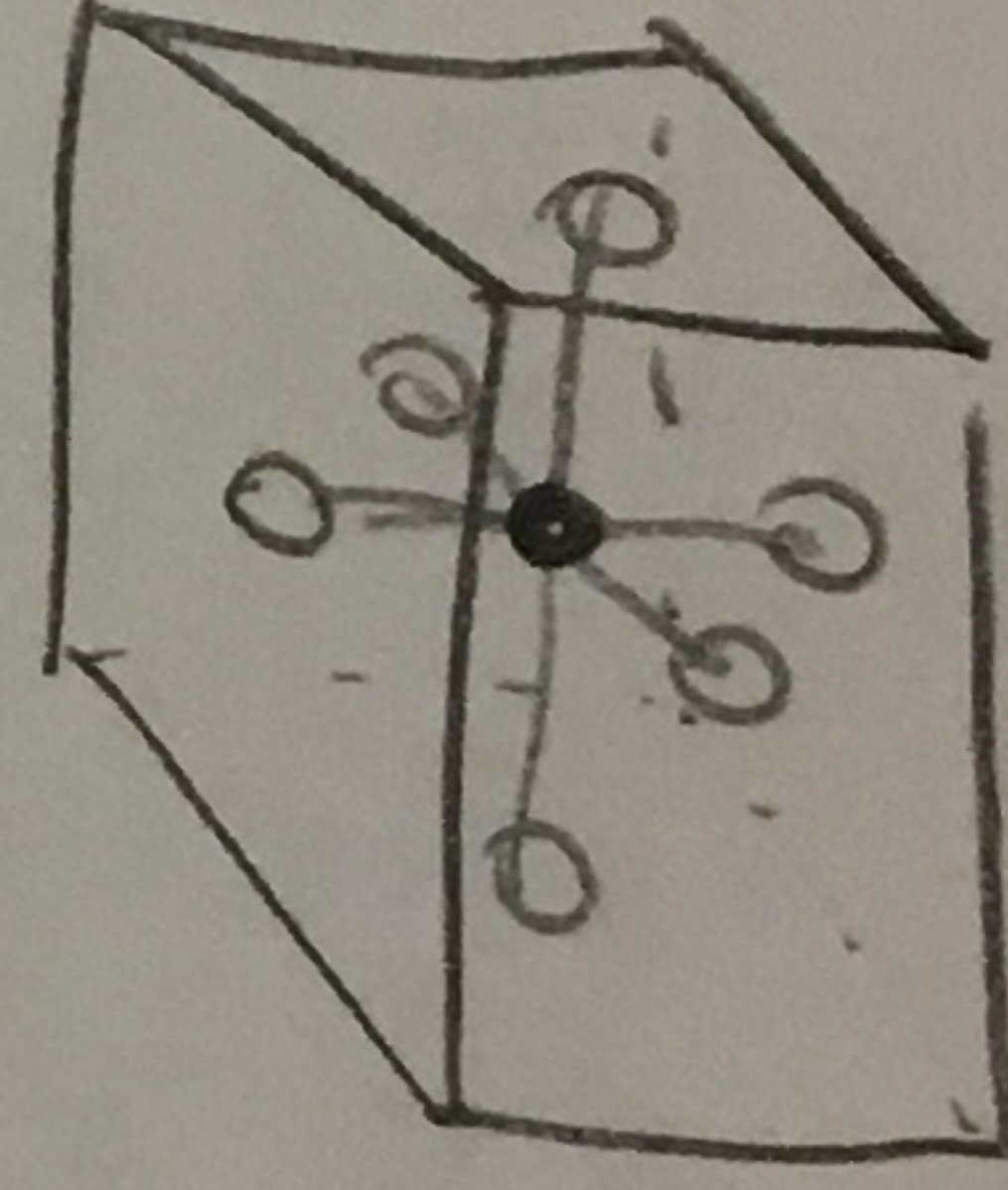
**Show all work and must include units to receive full credit.**  
**Check that all parts are answered.**

1. (a) Will each of the following elements act as a donor (n-type) or acceptor (p-type) when added to the indicated host semiconductor. Assume impurity atoms substitute for the host atoms. Hint: In compound semiconductors, the impurity atom replaces the host atom closest to it. (10 pts)

<u>Impurity</u>	<u>Host semiconductor</u>	
P	Si	n-type
Ga	Ge	p-type
Se	InSb	n-type
In	CdS	n-type
As	ZnTe	p-type

- (b) Why is the permanent dipole in BaTiO<sub>3</sub> lost when it is in the cubic phase? (5 pts)

The titanium atom in cubic phase sits centrally in the atom, with its oxygens surrounding it symmetrically. Thus, there is no net dipole.



- (c) Would you expect SrTiO<sub>3</sub> to have a permanent dipole as BaTiO<sub>3</sub>? (Yes or no answer is sufficient) (5 pts)

yes



2. (a) Name all polarization mechanisms possible in NaCl? (Hint: possibilities are electronic, ionic and orientation polarization). (5 pts)

Electronic and Ionic

(b) A charge of  $2.0 \times 10^{-10}$  C is to be stored on each plate of a parallel plate capacitor having an area of  $650 \text{ mm}^2$  and a plate separation of  $4.0 \text{ mm}$ . Determine the following – remember to include units.

- What electric field must be applied if a material with dielectric constant of 4.5 is positioned within the plates? (4 pts)
- What is the capacitance of the capacitor in part (i)? (4 pts)
- What is the polarization for the capacitor in part (i) (4 pts)
- What is the surface charge density (also referred to as the dielectric displacement) for the capacitor in part (i). (4 pts)
- Which material will have the higher dielectric constant, pure  $\text{SiO}_2$  or  $\text{MgO-SiO}_2$ ? (4 pts) (No explanation necessary)

$$Q = 2.0 \times 10^{-10} \text{ C} \quad Q = CV \quad A = 650 \text{ mm}^2 = 6.5 \times 10^{-4} \text{ m}^2$$

$$d = 4.0 \text{ mm} = 0.004 \text{ m}$$

$$\text{i) } \epsilon_r = 4.5$$

$$C = \frac{\epsilon_r \epsilon_0 A}{d}$$

$$Q = CV \quad E = V/d$$

$$Q = CE d$$

$$Q = \frac{\epsilon_r \epsilon_0 A E d}{d}$$

$$E = Q / (\epsilon_r \epsilon_0 A)$$

$$E = 7726 \text{ V/m}$$

$$\text{ii) } C = \frac{\epsilon_r \epsilon_0 A}{d} = \frac{(4.5)(8.85 \times 10^{-12})(6.5 \times 10^{-4})}{0.004} = 6.4 \times 10^{-12} \text{ F}$$

$$\text{iii) } P = \epsilon_0 (\epsilon_r - 1) E$$

$$P = 2.39 \times 10^{-7} \text{ C/m}^2$$

$$D = \epsilon E = \epsilon_0 E + P$$

$$\epsilon_r \epsilon_0 E = \epsilon_0 E + P$$

$$\text{iv) } D = \epsilon \epsilon_0 E$$

$$D = 3.08 \times 10^{-7} \text{ C/m}^2$$

$$P = \epsilon_r \epsilon_0 E - \epsilon_0 E$$

$$P = \epsilon_0 E (\epsilon_r - 1)$$

v)  ~~$\epsilon_r$  polymer~~

MgO-SiO<sub>2</sub>

$$P = \epsilon_0 E (\epsilon_r - 1)$$

$\Rightarrow$  the one with greater polarization

$\text{SiO}_2$ : Electronic

$\text{MgO-SiO}_2$ : Electronic, ionic

$\Rightarrow \text{MgO-SiO}_2$  has greater polarization



(a) GaP has a band gap of 2.25 eV, over what wavelength region of visible light will it be transparent? Visible light is from 400 nm to 700 nm. (5 pts)

$$E = h\nu \quad c = \nu\lambda$$

$$2.25 \text{ eV} \leq (4.13 \times 10^{-15} \text{ eV}\cdot\text{s})(\nu)$$

$$\nu \geq 5.45 \times 10^{14} \text{ Hz}$$

$$\lambda \leq c/\nu$$

$$\Rightarrow \lambda \leq 5.507 \times 10^{-7} \text{ m}$$

→ GaP will absorb light with wavelength less than 550.7 nm.

Therefore it is transparent to wavelengths  $550.7 \text{ nm} < \lambda < 700 \text{ nm}$

3 (b) At room temperature, the electrical conductivity and the electron mobility for Al are  $3.8 \times 10^7 (\Omega\cdot\text{m})^{-1}$  and  $0.0012 \text{ m}^2/\text{V}\cdot\text{s}$ , respectively. (20 pts)

(i) Calculate the number of free electrons per  $\text{m}^3$  for Al at room temperature.

(ii) What is the number of free electrons per aluminum atom? Assume a density of  $2.7 \text{ g/cm}^3$ , and the atomic weight of Al is  $26.98 \text{ g/mol}$

(iii) What is ratio of free electrons/valence electrons per aluminum atom?

i)  $\sigma = 3.8 \times 10^7 \quad \mu_e = 0.0012 \text{ m}^2/\text{V}\cdot\text{s}$

$$\sigma = n_e e \mu_e$$

$$3.8 \times 10^7 = n_e (1.6 \times 10^{-19}) / 0.0012$$

$$\Rightarrow n_e = 1.98 \times 10^{29} \text{ free } e^-/\text{m}^3$$

ii)  $\rho_{\text{Al}} = 2.7 \text{ g/cm}^3 = 2.7 \times 10^6 \text{ g/m}^3$

$$M_{\text{Al}} = 26.98 \text{ g/mol}$$

$$\frac{2.7 \times 10^6 \text{ g/m}^3}{26.98 \text{ g/mol}} = 1 \times 10^5 \text{ mol/m}^3$$

$$(1 \times 10^5 \text{ mol Al/m}^3) (6.02 \times 10^{23}) = 6.02 \times 10^{28} \text{ Al/m}^3$$

$$\frac{n_e}{\# \text{ Al/m}^3} = \frac{1.98 \times 10^{29}}{6.02 \times 10^{28}} = 3.29 \text{ free electrons/Aluminum atom}$$

iii) # valence  $e^-$  per atom: 3

$$\frac{3.29}{3} = 1.097 \text{ free } e^-/\text{valence } e^-$$



30

4) A Si sample was found to have residual boron (B). The room temperature electrical conductivity of this Si sample with residual B was found to be  $0.080 \text{ } (\Omega\text{-m})^{-1}$ . B has a density of  $2.34 \text{ g/cm}^3$ . Si has a density of  $2.33 \text{ g/cm}^3$ , intrinsic conductivity of  $4 \times 10^{-4} \text{ } (\Omega\text{-m})^{-1}$ , with  $\mu_e = 0.19 \text{ m}^2/\text{V-sec}$  and  $\mu_h = 0.0425 \text{ m}^2/\text{V-sec}$  at room temperature. Atomic weights can be found in the periodic table on the last page. Assume that B atoms substitute for Si atoms and saturation is reached.

- (i) What was the atomic% of residual boron in this Si sample? (15 pts)
- (ii) If this sample was further doped with additional  $5 \times 10^{18} \text{ m}^{-3}$  of B atoms, what would be its electrical conductivity? (15 pts)

p-type

$$\rho_B = 2.34 \text{ g/cm}^3 \quad \rho_{Si} = 2.33 \text{ g/cm}^3$$

$$\sigma_{Si} = 4 \times 10^{-4}$$

$$\mu_e = 0.19 \text{ m}^2/\text{V-sec}$$

$$\mu_h = 0.0425 \text{ m}^2/\text{V-sec}$$

i)  $\sigma_{doped} = 0.080$

$$\frac{\sigma_{doped}}{\sigma_{intrinsic}} = \frac{0.080}{4 \times 10^{-4}} = 200 \times$$

$$\sigma_{doped} = n_h |e| \mu_h$$

$$0.080 = n_h (1.6 \times 10^{-19}) |0.0425$$

$$n_h = 1.18 \times 10^{19} \text{ holes/m}^3 \Rightarrow 1.18 \times 10^{19} \text{ B/m}^3$$

total # atoms: use Si density

$$M_{Si} = 28.086 \text{ g/mol}$$

$$\rho_{Si} = 2.33 \text{ g/cm}^3 = 2.33 \times 10^6 \text{ g/m}^3$$

$$\frac{2.33 \times 10^6 \text{ g/m}^3}{28.086 \text{ g/mol}} = 8.3 \times 10^{14} \text{ moles/m}^3$$

$$= 5 \times 10^{28} \text{ Si/m}^3$$

$$\text{atomic \%} = 100 \left( \frac{\# \text{ B atoms}}{\# \text{ atoms}} \right) = 100 \left( \frac{1.18 \times 10^{19}}{5 \times 10^{28}} \right)$$

$$\boxed{\text{atomic \% B} = 2.35 \times 10^{-8} \%}$$

ii)  $\Rightarrow 1.18 \times 10^{19} \text{ B/m}^3 + 5 \times 10^{18} \text{ B/m}^3 = 1.68 \times 10^{19} \text{ B/m}^3$

$$\Rightarrow 1.68 \times 10^{19} \text{ holes/m}^3$$

$$\sigma = n_h |e| \mu_h$$

$$\sigma = (1.68 \times 10^{19}) (1.6 \times 10^{-19}) (0.0425)$$

$$\boxed{\sigma = 0.11424 \text{ } (\Omega\text{-m})^{-1}}$$